

East of USPB, USPT, WPID, JPO

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	40503	implant\$ same (resist or photoresist or mask or photomask or imaging)	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:20
L2	2308085	etch\$ or patern\$ or remov\$	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:40
L3	25873	1 same 2	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:19
L4	919309	"h2" or he or "h.sub.2" or hydrogen or helium	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:40
L5	29686	implant\$ with (resist or photoresist or mask or photomask or imaging)	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:39
L6	320	4 with 5	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:20
L7	178	2 same 6	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:21
L8	9354	blanket\$ with 2	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:30
L9	6	7 same 8	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:23
L10	20	7 and 8	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:23
L11	14	10 not 9	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:23
L12	4997	(implant\$ with (resist or photoresist or mask or photomask or imaging)).clm.	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:29
L13	625167	(etch\$ or patern\$ or remov\$).clm.	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:29
L14	1268	blanket\$.clm. with 13	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:30
L15	73	12 and 13 and 14	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:30
L16	269136	("h2" or he or "h.sub.2" or hydrogen or helium).clm.	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:30
L17	30	12 with 16	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:31
L18	0	15 and 17	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:32
L19	1442	5 and 8	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:32
L20	337	5 same 8	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:33

L21	324	20 not 10	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:33
L22	536	"blanket\$ etch\$" or "blanket\$ patern\$"	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:39
L23	11	5 same 22	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:34
L24	11	23 not 10	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:35
L25	119	5 and 22	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:36
L26	105	25 not (10 or 23)	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:37
L27	320	4 with 5	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:37
L28	0	26 and 27	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:37
L29	4122	implant\$ with 4	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:38
L30	320	27 and 29	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:38
L31	2	26 and 29	US-PGPUB; USPAT	OR	OFF	2004/12/02 20:38
L32	14413	implant\$ with (resist or photoresist or mask or photomask or imaging)	JPO; DERWENT	OR	OFF	2004/12/02 20:39
L33	66	"blanket\$ etch\$" or "blanket\$ patern\$"	JPO; DERWENT	OR	OFF	2004/12/02 20:39
L34	1636318	etch\$ or patern\$ or remov\$	JPO; DERWENT	OR	OFF	2004/12/02 20:40
L35	513042	"h2" or he or "h.sub.2" or hydrogen or helium	JPO; DERWENT	OR	OFF	2004/12/02 20:40
L36	3	32 and 33 and 34	JPO; DERWENT	OR	OFF	2004/12/02 20:41
L37	0	35 and 36	JPO; DERWENT	OR	OFF	2004/12/02 20:41
L38	126	32 with 35	JPO; DERWENT	OR	OFF	2004/12/02 20:41
L39	82	34 and 38	JPO; DERWENT	OR	OFF	2004/12/02 20:42
L40	82	35 and 39	JPO; DERWENT	OR	OFF	2004/12/02 20:42